

AN 118:49768 HCA  
TI Cast **sputtering targets** for preparation of reflective  
films of optical recording media  
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SO Jpn. Kokai Tokkyo Koho, 4 pp.  
CODEN: JKXXAF

DT Patent  
LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 04099171	A2	19920331	JP 1990-5139	19900111
	JP 07018003	B4	19950301		

AB The target is made of an Al-base alloy contg. Ta, **Nb**, and/or V  
0.5-10 at.% and has uniform dispersion of Al-Group VB intermetallic  
compd(s). (e.g., .ltoreq.100 .mu.m in **grain** size) in a matrix of  
Al. O content in the alloy may be .ltoreq.200 ppm. The reflective film  
prepd. is corrosion-resistant.